

LETTERS

Carbon monoxide-induced reduction and healing of graphene oxide

Badri Narayanan, Stephen L. Weeks, Bhavin N. Jariwala, Bart Macco, Jan-Willem Weber, Somilkumar J. Rathi, Mauritius C. M. van de Sanden, Peter Sutter, Sumit Agarwal and Cristian V. Ciobanu

J. Vac. Sci. Technol. A **31**, 040601 (2013); <http://dx.doi.org/10.1116/1.4803839>

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Epitaxial $V_{0.6}W_{0.4}N/MgO(001)$: Evidence for ordering on the cation sublattice

H. Kindlund, J. Lu, J. Jensen, I. Petrov, J. E. Greene and L. Hultman

J. Vac. Sci. Technol. A **31**, 040602 (2013); <http://dx.doi.org/10.1116/1.4807654>

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REVIEW ARTICLE

Fabrication of organic interfacial layers by molecular layer deposition: Present status and future opportunities

Han Zhou and Stacey F. Bent

J. Vac. Sci. Technol. A **31**, 040801 (2013); <http://dx.doi.org/10.1116/1.4804609>

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PLASMA SCIENCE AND TECHNOLOGY

Effect of bias application to plasma density in weakly magnetized inductively coupled plasma

Hyuk Kim, Woohyun Lee, Wanjae Park and Ki-Woong Whang

J. Vac. Sci. Technol. A **31**, 041301 (2013); <http://dx.doi.org/10.1116/1.4804136>

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Roles of plasma-generated vacuum-ultraviolet photons and oxygen radicals in damaging nanoporous low- k films

Joe Lee and David B. Graves

J. Vac. Sci. Technol. A **31**, 041302 (2013); <http://dx.doi.org/10.1116/1.4807299>

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Effects of He and Ar ion kinetic energies in protection of organosilicate glass from O_2 plasma damage

Joe Lee, Haseeb Kazi, Sneha Gaddam, Jeffrey A. Kelber and David B. Graves

J. Vac. Sci. Technol. A **31**, 041303 (2013); <http://dx.doi.org/10.1116/1.4809579>

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Stability and etching of titanium oxynitride films in hydrogen microwave plasma

Hien Do, Tzu-Chun Yen and Li Chang

